

# Supporting Information

## Deactivation-Free Ethanol Steam Reforming at Nickel-Tipped Carbon Filaments

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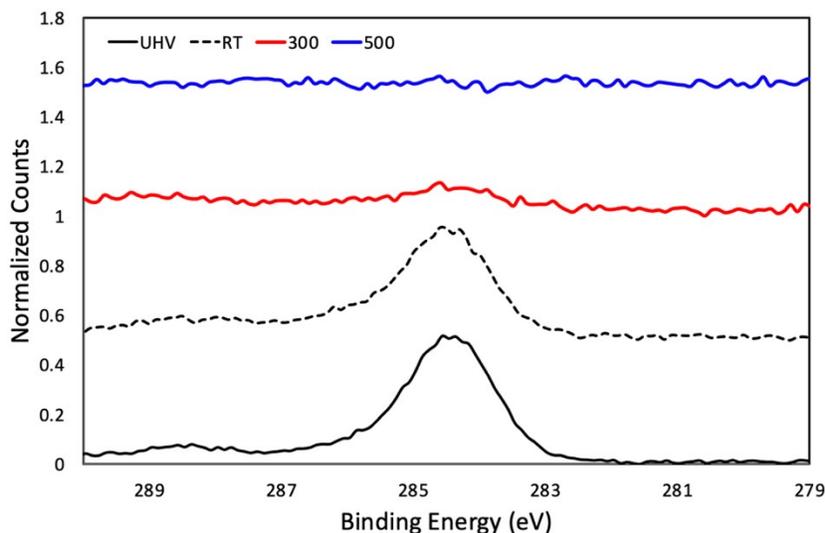
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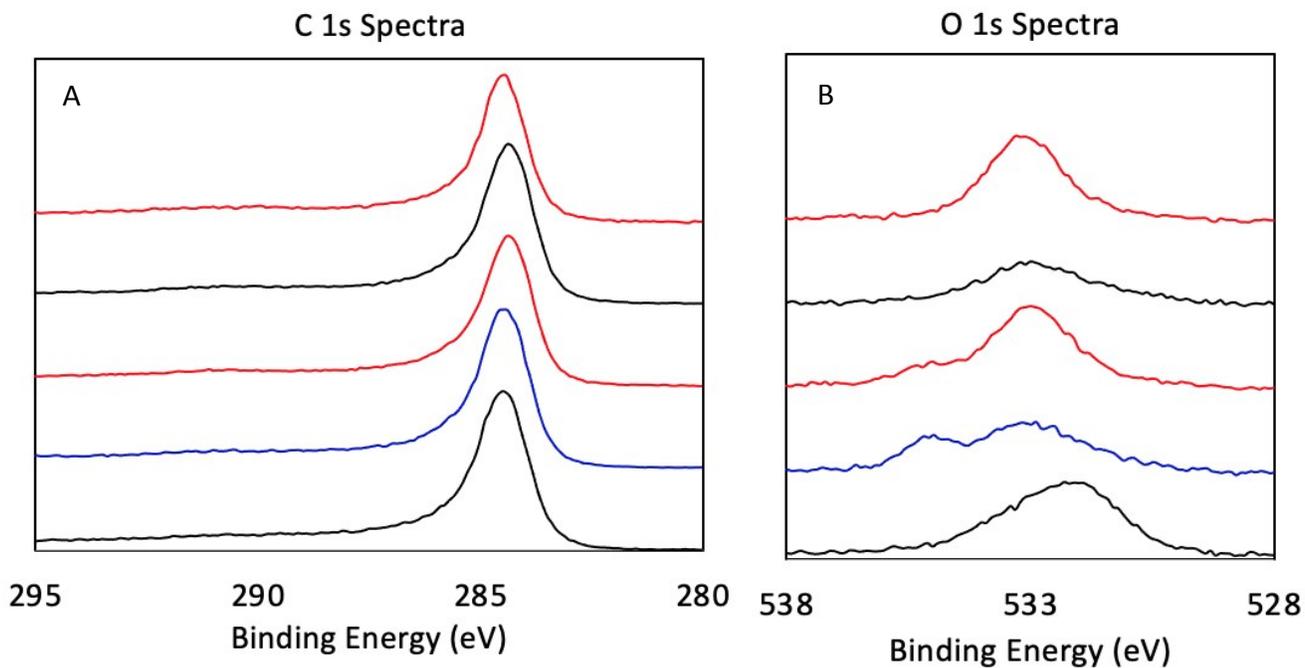
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## 1. Carbon Removal from CeO<sub>2</sub> Nanocubes by Catalyst Pre-Treatment



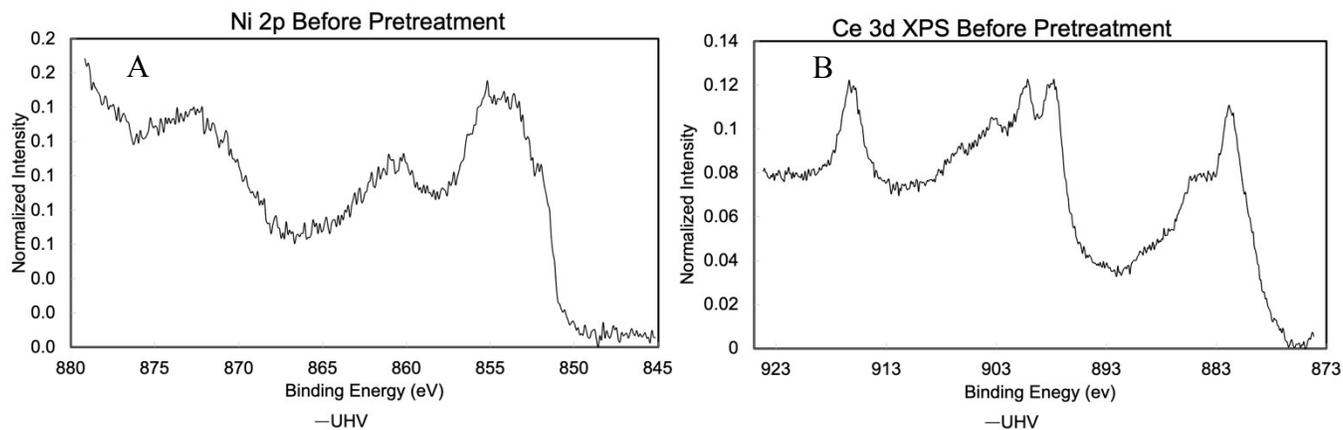
**Figure S1** C 1s NAP-XPS spectra of a Ni/CeO<sub>2</sub> catalyst collected under 0.75 Torr O<sub>2</sub> as a function of increasing temperature. The broad feature centered at 284.5 eV represents aliphatic carbon, and the shoulder at higher binding energy represents carbon-oxygenates. Both features disappear completely by 500 °C indicating that complete removal of organic capping ligands is achieved during the calcination conditions employed for catalyst pre-treatment.

## 2. C 1s and O 1s NAP-XPS Spectra of the Ni@CFIL Active Phase



**Figure S2.** In situ NAP-XPS measurements of the C 1s spectrum (**A**) and the O 1s spectrum (**B**) on Ni/CeO<sub>2</sub>. Spectra are obtained in 0.75 Torr of a 1:3 ethanol:water mixture at 280 °C (blue spectra) and 360 °C (red spectra) following the ex situ formation of the Ni@CFIL active phase. For reference spectra of the Ni@CFIL active phase under UHV at room temperature is shown in black. These spectra correspond with the Ni 2p and Ce 3d spectra reported in Figure 3 of the main manuscript.

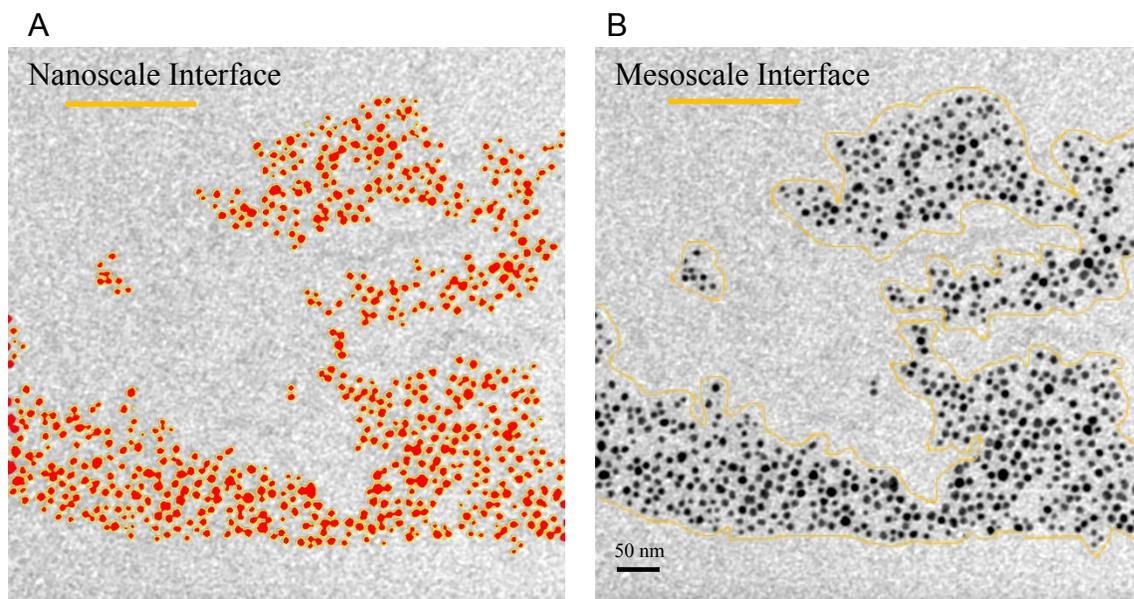
### 3. Pre-Reaction XPS Spectra of Ni/CeO<sub>2</sub> Catalyst



**Figure S3.** Ni 2p (A) and Ce 3d (B) XPS spectrum of as prepared Ni/CeO<sub>2</sub> catalyst prior to reaction.

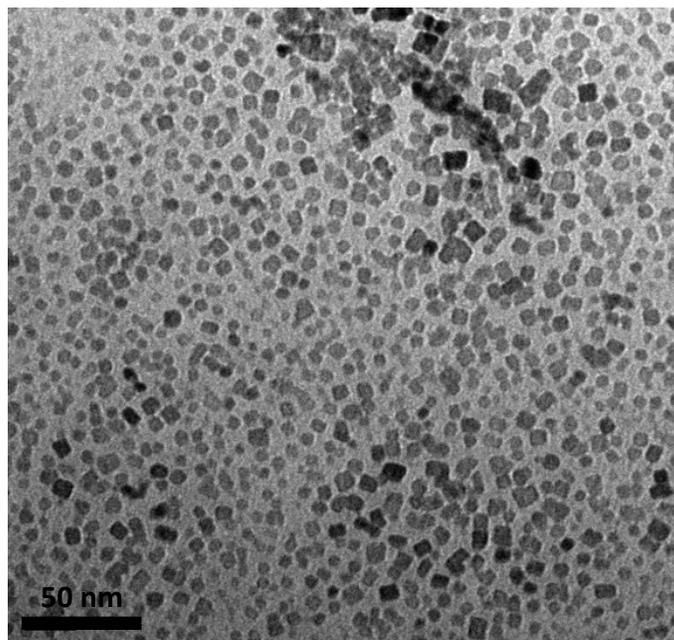
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#### 4. Quantification of Nanoscale and Mesoscale Interface Density



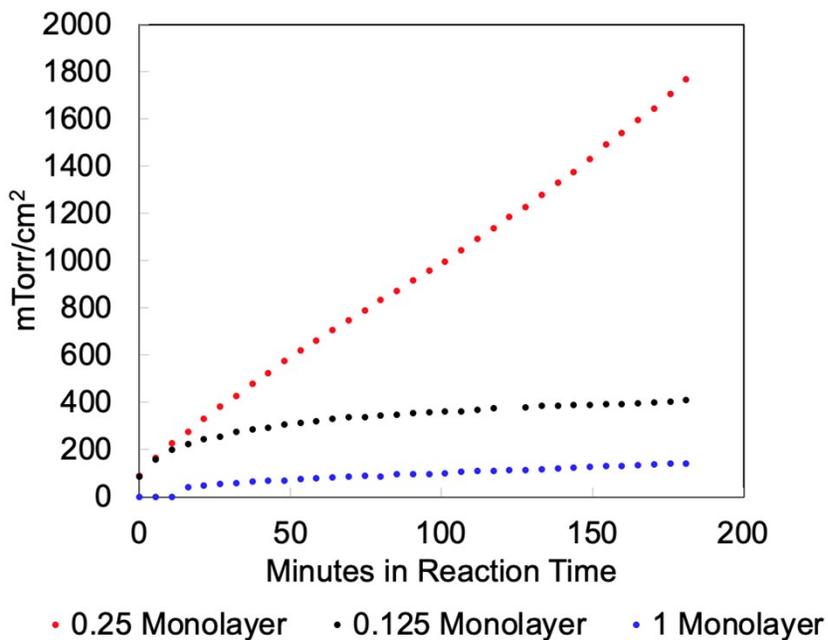
**Fig S4** Image analysis for quantification of nanoscale interface (**A**) and the mesoscale interface (**B**). Nanoscale interface is defined as the total boundary length in nm around individual nanoparticles per nm<sup>2</sup> of the total catalyst. Mesoscale interfaces is defined as the boundary length in nm around the perimeter of closely packed domains of CeO<sub>2</sub> nanocubes per per nm<sup>2</sup> of the total catalyst. Similar image analysis was performed on numerous images of CeO<sub>2</sub> nanocubes deposited at various total coverages, resulting in the quantification with error bars of nano and mesoscale interface density shown in Figure 5 of the main manuscript.

## 5. Thermal Stability of CeO<sub>2</sub> Nanocubes



**Fig S5.** TEM images of CeO<sub>2</sub> nanocubes supported on Si<sub>3</sub>N<sub>4</sub> membranes following calcination at 500 °C in O<sub>2</sub> and subsequent reduction at 250 °C in H<sub>2</sub>. These images can be compared with the image of as-deposited nanocubes in Figure 6A of the main manuscript confirming that the morphology of CeO<sub>2</sub> nanocubes is unchanged before and after pre-treatment and that the degree of nanoparticle sintering is very low.

## 6. Coverage-Dependent Deactivation Profiles of Ni/CeO<sub>2</sub> Catalysts



**Figure S6.** Deactivation profiles of H<sub>2</sub> production on Ni/CeO<sub>2</sub> catalysts as a function of CeO<sub>2</sub> nanocube coverage, corresponding to Figure 5D in the main manuscript. Results show that the mesoscale morphology resulting from a 0.25 monolayer coverage of CeO<sub>2</sub> nanocubes on Ni results not only in the highest activity, but also significantly increased resistance to deactivation.

## 7. Calculation of Turnover Frequency

H<sub>2</sub> production rates normalized to the geometric surface area of the planar catalysts are reported in Figure 5D of the main manuscript. Below we convert these rates to an approximate turnover frequency (TOF) for each catalyst. First, we calculate the number of H<sub>2</sub> molecules produced by

$$N_{H_2} = \frac{P \cdot V \cdot N_A}{R \cdot T}$$

where P is the H<sub>2</sub> pressure measured by gas chromatography, V is reactor volume (0.5 L), N<sub>A</sub> is Avogadro's number, R is the ideal gas constant (62.36 L Torr K<sup>-1</sup> mol<sup>-1</sup>), and T is temperature of the gas phase (298 K).

To convert the H<sub>2</sub> production rate to a TOF, it is necessary to estimate the number of active sites. Unfortunately, it is not possible to directly measure the Ni dispersion in these planar catalysts. Consequently, we assume a Ni site density of  $1.86 \times 10^{15} \text{ cm}^{-2}$  based on a clean Ni (111) surface prior to deposition of CeO<sub>2</sub> nanocubes. In reality, this represents an upper estimate of the active site density because only a small fraction of the total Ni surface area in the as-prepared catalyst is actually incorporated into the Ni@CFIL active phase (see Figures 2 and 3 of the main manuscript). Although this value underestimates the actual TOF, this provides a useful approximation for comparing the activity of the Ni@CFIL active phase to previously reported catalysts.

Assuming an ideal reaction stoichiometry of  $\text{CH}_3\text{CH}_2\text{OH} + 3 \text{H}_2\text{O} \rightarrow 6 \text{H}_2 + 2 \text{CO}_2$ , the rate of H<sub>2</sub> production is converted to a TOF in units of ethanol molecules site<sup>-1</sup> s<sup>-1</sup> by

$$TOF = \frac{N_{H_2}}{6 \cdot 1.86 \times 10^{15} \cdot A \cdot t}$$

where A is the geometric surface area in cm<sup>2</sup>, and t is the total reaction time in s. Table S1 below provides the calculated TOF for Ni/CeO<sub>2</sub> catalysts as a function of CeO<sub>2</sub> nanocube coverage as well as for the pure Ni catalyst.

**Table S1** H<sub>2</sub> production rate and TOF for Ni/CeO<sub>2</sub> catalysts as a function of CeO<sub>2</sub> nanocube coverage compared to pure Ni.

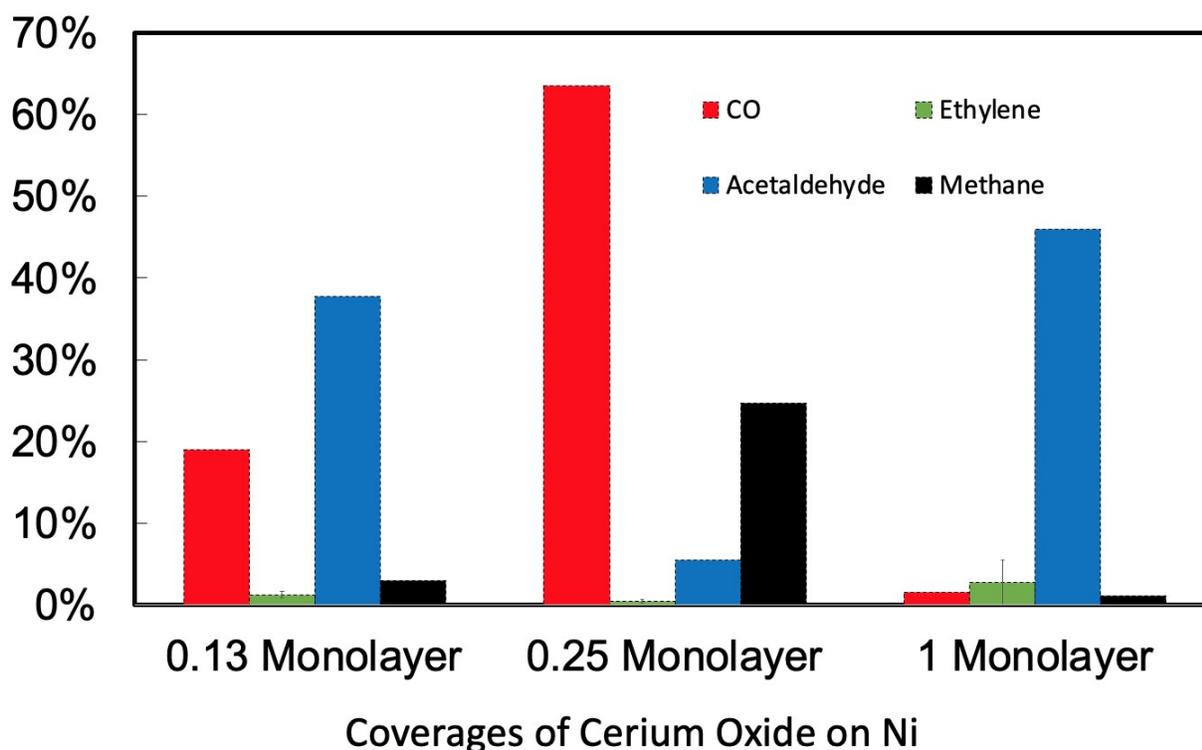
| Catalyst                             | H <sub>2</sub> Rate (mTorr cm <sup>-2</sup> min <sup>-1</sup> ) | TOF (s <sup>-1</sup> ) |
|--------------------------------------|---|------------------------|
| Ni/CeO <sub>2</sub> (0.13 monolayer) | 1.1   | 0.027                  |
| Ni/CeO <sub>2</sub> (0.25 monolayer) | 8.7   | 0.21                   |
| Ni/CeO <sub>2</sub> (1.0 monolayer)  | 0.71  | 0.017                  |
| Pure Ni                              | 0.43  | 0.010                  |

## 8. Carbon Selectivity of Ni/CeO<sub>2</sub> Catalysts

Selectivity for the C products is defined as

$$S_j = \frac{P_j \cdot n_j}{\sum_j P_j \cdot n_j} \times 100$$

where  $P_j$  is the pressure of the  $j^{\text{th}}$  C-containing product, and  $n_j$  is the number of C atoms in respective product. At the relatively low temperatures employed in this study, H<sub>2</sub> production results primarily from the dehydrogenation of ethanol to produce acetaldehyde followed by the decomposition of acetaldehyde to produce CO and methane. CeO<sub>2</sub> is known to promote the water gas shift reaction as well as methane reforming leading to CO<sub>2</sub>. However, consistent with the absence of CeO<sub>2</sub> from the Ni@CFIL active phase (see Figures 2 and 3), we observe only trace amounts of CO<sub>2</sub>. Rather, primary C products observed here are CO, ethylene, acetaldehyde, and methane, and selectivity on the Ni/CeO<sub>2</sub> as a function of CeO<sub>2</sub> nanocube coverage is provided in Figure S6.



**Figure S7** Selectivity of Ni/CeO<sub>2</sub> catalysts for C products as a function of CeO<sub>2</sub> nanocube coverage.

